

**AMENDMENTS TO THE CLAIMS**

This listing of claims will replace all prior versions and listings of claims in the application:

**LISTING OF CLAIMS:**

1. (currently amended): An organic electroluminescent (EL) display, comprising:  
a plurality of ITO films which are disposed on a transparent substrate via an inter-layer insulating film;  
an a first insulating film which is disposed between adjacent ones of said ITO films;  
an organic EL thin film deposited on said ITO films;  
a cathode thin film deposited on said ITO films; and  
a plurality of insulative mask supporting layers constituting a part of or a whole of said first insulating film, said mask supporting layers preventing a metal mask which is used in formation of said organic EL thin film and said cathode thin film, from being in contact with a pixel portion of said transparent substrate.
2. (original): The organic EL display according to claim 1, wherein said display uses a TFT substrate in which said ITO films and TFT layers that are disposed via said interlayer insulating film are connected to one another in an active matrix system.
3. (original): The organic EL display according to claim 1, wherein said mask supporting layers are formed by one of a resist, ceramics and an organic resin.

4. (original): The organic EL display according to claim 1, wherein said insulative mask supporting layers having a reverse tapered shape are disposed on said insulating film.

5. (withdrawn): A method of producing an organic EL display, said method comprising the steps of:

disposing a plurality of ITO films on a transparent substrate via an inter-layer insulating film;

disposing a plurality of mask supporting layers on said inter-layer insulating film;

overlaying a metal mask of a predetermined pattern having openings therein on said transparent substrate so as to support said metal mask by said mask supporting layers; and

depositing an organic EL thin film and a cathode thin film on said ITO films through the openings of said metal mask.

6. (withdrawn): The method of producing an organic EL display according to claim 5, further comprising the steps of: disposing said ITO films and TFT layers on said transparent substrate via said inter-layer insulating film;

connecting said ITO films and said TFT layers to one another in an active matrix system;

and

then forming said mask supporting layer.

7. (new): An organic electroluminescent (EL) display, comprising:
- a plurality of ITO films which are disposed on a transparent substrate via an inter-layer insulating film;
  - a first insulating film which is disposed between adjacent ones of said ITO films;
  - an organic EL thin film deposited on said ITO films;
  - a cathode thin film deposited on said ITO films; and
  - a plurality of insulative mask supporting layers disposed on at least a part of said first insulating film, said mask supporting layers preventing a metal mask which is used in formation of said organic EL thin film and said cathode thin film, from being in contact with a pixel portion of said transparent substrate.
8. (new): The organic EL display according to claim 7, wherein said insulative mask supporting layers are formed from said first insulating layer.
9. (new): The organic EL display according to claim 7, wherein said insulative mask supporting layers are formed on said first insulating layer.
10. (new): The organic EL display according to claim 7, wherein said insulative mask supporting layers are stripe-shaped.
11. (new): The organic EL display according to claim 7, wherein said insulative mask supporting layers are island-shaped.

13. (new): The organic EL display according to claim 7, wherein said insulative mask supporting layers have a thickness of at least 2  $\mu\text{m}$ .

14. (new): The organic EL display according to claim 7, wherein said insulative mask supporting layers have at least one portion which is either taper-shaped or ridge-shaped.

15. (new): The organic EL display according to claim 8, wherein said insulative mask supporting layers are constituted by locally thickened portions of said first insulating layer.

16. (new): The organic EL display according to claim 9, wherein said insulative mask supporting layers are formed directly on said first insulating layer.

17. (new): The organic EL display according to claim 7, wherein said insulative mask supporting layers is disposed such that a predetermined gap is maintained between a corresponding one of said ITO films and said metal mask.